

Substitute for form 1449A/PTO

**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

(use as many sheets as necessary)

Sheet 1 of 2

Complete if Known

Application Number	09/608,624
Filing Date	June 30, 2000
First Named Inventor	JOURDAN et al
Group Art Unit	2183
Examiner Name	H. Tsai
Attorney Docket Number	21207/8609

U.S. PATENT DOCUMENTS

Examiner Initials *	Cite No. ¹	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number - Kind Code ² (if known)			
125		US- 6,076,144	06/13/00	Peled et al	
1		US- 6,351,844 B1	02/26/02	Bala	
125		US- 6,073,213	06/06/00	Peled	
		US- 6,339,822 B1	01/15/02	Miller	

FOREIGN PATENT DOCUMENTS

Examiner Initials *	Cite No. ¹	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T ²
		Country Code ³ - Number ⁴ - Kind Code ⁵ (if known)				

OTHER PRIOR ART -- NON PATENT LITERATURE DOCUMENTS

Examiner Initials *	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
125		Jourdan et al, "Extended Block Cache", Proceedings of the Sixth International Symposium on High-Performance Computer Architecture, Toulouse, France, January 8-12, 2000	
125		Hennessey & Patterson, <i>Computer Organization and Design</i> , 2nd Edition, page 570, 1998	
125		Rotenbery et al, "Trace Processors", Proceedings of 30th Annual IEEE/ACM International Symposium on Microarchitecture, pp. 138-148, December 1, 1997	

Examiner
Signature*H. Tsai*Date
Considered

2/17/04

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.